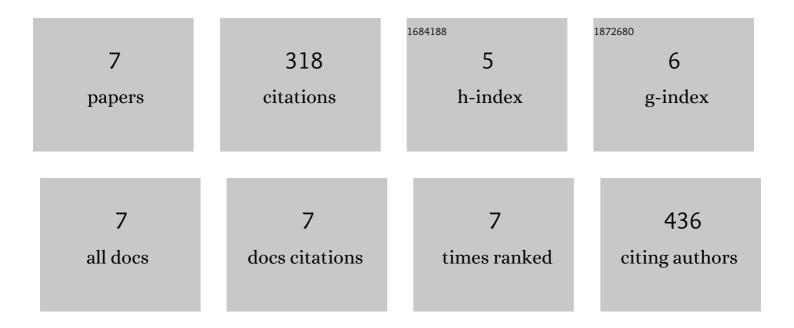
Nelson Felix

List of Publications by Year in descending order

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#	Article	IF	CITATIONS
1	Directed self-assembly of block copolymers for 7 nanometre FinFET technology and beyond. Nature Electronics, 2018, 1, 562-569.	26.0	87
2	DSA patterning options for FinFET formation at 7nm node. Proceedings of SPIE, 2016, , .	0.8	6
3	Molecular glass resists for next generation lithography. Proceedings of SPIE, 2008, , .	0.8	6
4	Phenolic molecular glasses as resists for next-generation lithography. , 2007, 6519, 1291.		24
5	Sub-50 nm feature sizes using positive tone molecular glass resists for EUV lithography. Journal of Materials Chemistry, 2006, 16, 1470.	6.7	83
6	Molecular Glass Resists for High-Resolution Patterning. Chemistry of Materials, 2006, 18, 3404-3411.	6.7	104
7	New PFOS Free Photoresist Systems for EUV Lithography. Journal of Photopolymer Science and Technology = [Fotoporima Konwakai Shi], 2006, 19, 515-520.	0.3	8